

	L #	Hits	Search Text	DBs	Time Stamp
1	L1	11926	(smooth\$3 roughness) near20 (si or silicon or semiconductor)	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 14:35
2	L8	759906	hydrogen or "H.sub.2"	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 14:36
3	L15	2117	1 same etch\$3	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 14:45
4	L22	342	15 same (anneal\$3 heat\$3 bak\$3)	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 15:31
5	L29	46	22 same 8	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 14:39
6	L36	1223	1 near20 etch\$3	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 14:45
7	L43	131	36 same (anneal\$3 heat\$3 bak\$3)	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 14:46
8	L50	25	43 same 8	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 15:26
9	L57	2	5744401.URPN.	USPAT	2002/03/05 15:18
10	L58	49	("6326279" "6306729" "6255731" "6246068" "6180497" "6171982" "6103598" "6103009" "5876497" "5854123").urpn.	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 15:28

	L #	Hits	Search Text	DBs	Time Stamp
11	L65	33 )	58 and etch\$3	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 15:28
12	L72	47	58 and (anneal\$3 heat\$3 bak\$3)	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 15:31
13	L79	38	58 and ((anneal\$3 heat\$3 bak\$3) same (8 or HCl or hydrochloric or hydrofluoric or hydrobromic or hydroiodic or HBr or HF or HI or chlorine or fluorine or bromine or iodine or halogen or "Cl.sub.2" "Br.sub.2" "F.sub.2" "I.sub.2" or cl br f i))	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 15:47
14	L86	11	58 and ((anneal\$3 heat\$3 bak\$3) same (HCl or hydrochloric or hydrofluoric or hydrobromic or hydroiodic or HBr or HF or HI or chlorine or fluorine or bromine or iodine or halogen or "Cl.sub.2" "Br.sub.2" "F.sub.2" "I.sub.2" or cl br f i))	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 16:01
15	L93	1479	1 and ((anneal\$3 heat\$3 bak\$3) same (HCl or hydrochloric or hydrofluoric or hydrobromic or hydroiodic or HBr or HF or HI or chlorine or fluorine or bromine or iodine or halogen or "Cl.sub.2" "Br.sub.2" "F.sub.2" "I.sub.2" or cl br f i))	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 16:04
16	L100	715	1 and ((anneal\$3 heat\$3 bak\$3) near25 (HCl or hydrochloric or hydrofluoric or hydrobromic or hydroiodic or HBr or HF or HI or chlorine or fluorine or bromine or iodine or halogen or "Cl.sub.2" "Br.sub.2" "F.sub.2" "I.sub.2" or cl br f i))	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 16:05
17	L107	359	1 and ((anneal\$3 heat\$3 bak\$3) same (HCl or hydrochloric or hydrofluoric or hydrobromic or hydroiodic or HBr or HF or HI or chlorine or fluorine or bromine or iodine or halogen or "Cl.sub.2" "Br.sub.2" "F.sub.2" "I.sub.2" or cl br f i) same 8)	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 16:05
18	L121	9	1 same ((anneal\$3 heat\$3 bak\$3) near25 (HCl or hydrochloric or hydrofluoric or hydrobromic or hydroiodic or HBr or HF or HI or chlorine or fluorine or bromine or iodine or halogen or "Cl.sub.2" "Br.sub.2" "F.sub.2" "I.sub.2" or cl br f i) same 8)	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 16:13
19	L114	121	1 and ((anneal\$3 heat\$3 bak\$3) near25 (HCl or hydrochloric or hydrofluoric or hydrobromic or hydroiodic or HBr or HF or HI or chlorine or fluorine or bromine or iodine or halogen or "Cl.sub.2" "Br.sub.2" "F.sub.2" "I.sub.2" or cl br f i) same 8)	USPAT; US-PGPU B; EPO; JPO; DERWENT ; IBM_TDB	2002/03/05 16:45
20	L128	2	5141878.URPN.	USPAT	2002/03/05 17:11
21	L129	12	5239193.URPN.	USPAT	2002/03/05 17:12

	L #	Hits	Search Text	DBs	Time Stamp
22	L130	29	5869387.URPN.	USPAT	2002/03/05 17:48
23	L131	6	6008128.URPN.	USPAT	2002/03/05 17:55
24	L132	1	"5846321".PN.	USPAT	2002/03/05 18:03
25	L133	1	"5885346".PN.	USPAT	2002/03/05 18:07
26	L134	1	"5846321".PN.	USPAT	2002/03/05 18:10
27	L135	1	"5869387".PN.	USPAT	2002/03/05 18:11